

限用物質含有情況標示聲明書

Declaration of the Presence Condition of the Restricted Substances Marking

證書號碼／受理編號：

Certificate No./Application No.

商品標籤及商品檢驗標識：(Picture)

Product Label and Commodity Inspection Mark.

樣張及其標示位置：(Description and Picture)

Sample and its location

限用物質含有情況提供於網站

<http://www.heran.com.tw>

設備名稱：分離式空氣調節機，型號（型式）：HI-GA50H／HO-GA50CH						
Equipment name		Type designation (Type)		系列型號：HI-GA50／HO-GA50C		
單元 Unit	限用物質及其化學符號 Restricted substances and its chemical symbols					
	鉛Lead (Pb)	汞Mercury (Hg)	鎘Cadmium (Cd)	六價鉻 Hexavalent chromium (Cr ⁺⁶)	多溴聯苯 Polybrominated biphenyls (PBB)	多溴二苯醚 Polybrominated diphenyl ethers (PBDE)
遙控器元件	—	○	○	○	○	○
室內機元件	○	○	○	○	○	○
內機電路板	—	○	○	○	○	○
內機馬達	○	○	○	○	○	○
室外機元件	○	○	○	○	○	○
外機電路板	—	○	○	○	○	○
外機馬達	○	○	○	○	○	○
壓縮機元件	—	○	○	○	○	○

備考1. “超出0.1 wt %”及“超出0.01 wt %”係指限用物質之百分比含量超出百分比含量基準值。
Note 1: “Exceeding 0.1 wt %” and “exceeding 0.01 wt %” indicate that the percentage content of the restricted substance exceeds the reference percentage value of presence condition.

備考2. “○”係指該項限用物質之百分比含量未超出百分比含量基準值。
Note 2: “○” indicates that the percentage content of the restricted substance does not exceed the percentage of reference value of presence.

備考3. “—”係指該項限用物質為排除項目。
Note 3: The “—” indicates that the restricted substance corresponds to the exemption.

茲切結保證所提供之商品限用物質含有情況標示內容係經執行測試作業或採適當之品質管理措施，並備置前述相關文件，確認正確無誤後提供貴局。並同意配合貴局執行後市場管理作業所需，依商品檢驗法第49條之規定，於限期28個工作天內提供相關證明文件以供審查。

I hereby ensure that “the presence conditions of the restricted substance” provided above have been proved by testing or appropriate quality control measures, and make sure the relevant documents provided are correct and ready. Also, I agree to cooperate with BSMI, as the Article 49 of the Commodity Inspection Act stipulates, to provide the relevant documents, if needed, for verification within 28 working days when BSMI carries out the market surveillance activities.

此致 to

財團法人台灣電子檢驗中心 Electronics Testing Center, Taiwan

申請人：聯碩電器股份有限公司華亞廠

Applicant

負責人：蔡金土 (簽章)

Person in charge

(Signature)

中華民國 107 年 2 月 21 日
DATE (year) (month) (day)